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# IN THE UNITED STATES PATENT & TRADEMARK OFFICE

IN RE APPLICATION OF

:

HERMAN P. GODFRIED, ET AL.

: EXAMINER: HENDRICKSON, S. L.

SERIAL NO: 10/717,566

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FILED: NOVEMBER 21, 2003

: GROUP ART UNIT: 1793

RCE FILED: HEREWITH

FOR: OPTICAL QUALITY DIAMOND

**MATERIAL** 

# DECLARATION UNDER 37 C.F.R. § 1.132

COMMISSIONER FOR PATENTS ALEXANDRIA, VIRGINIA 22313

SIR:

- I, Geoffrey Alan Scarsbrook, declare and state as follows:
- 1. I am a named coinventor in the above-identified application.
- 2. I am familiar with the claims, and have read the Office Action mailed May 21, 2008, in the above-identified application.
- 3. The active claims in the above-identified application have been rejected over each of US 6,582, 513 (Linares et al), US 5,443,032 (Vichr et al), JP 7-277890 (JP '890), and an article by Michler et al, Complementary application of electron microscopy and micro-Raman spectroscopy for microstructure, stress, and bonding defect investigation of heteroepitaxial chemical vapor deposited diamond films (Michler et al). The following declaration is offered to explain how one of ordinary skill in the art would interpret terms such as "high purity" and "high quality" in the context of single crystal diamond

Application No. 10/717,566

Declaration under 37 C.F.R. § 1.132

homoepitaxially deposited by a chemical vapor deposition (CVD) process, and how the presently-claimed invention is patentable over the applied prior art.

# The basic science of diamond as a material

- 4. A crystal is a material which can usefully be described in terms of a regular crystal lattice (a regular array of points which extends, at least conceptually, infinitely in all directions) with one or more atoms, known as the "motif", attached to each lattice point, such that the atoms attached to each lattice point are identical and every atom is associated with a single lattice point. Thus the crystal is formed by "lattice" plus the "motif". A "perfect crystal" can thus be described as a lattice in which the correct motif is associated with every lattice point and which extends infinitely.
- 5. Any real crystal cannot meet these criteria since it is finite (i.e. bounded by surfaces). Whilst it is theoretically possible that a crystal that is perfect in other respects could exist, perfection is generally only ever approached but never actually reached. Both thermodynamics and the detailed kinetics of growth tend to cause the incorporation of defects, and only an infinitesimal growth rate (to avoid kinetic problems) at a temperature of absolute zero (to avoid entropy issues) could deliver a perfect crystal (i.e. for all practical purposes it is impossible).
- 6. Crystals, and in particular diamond crystals, can have the following defects compared to the idealized perfect finite crystal:

point defects, such as vacancies, self-interstitials, impurities atoms and combinations of these, and,

extended defects, such as dislocations and stacking faults.

7. In addition, the crystal may be disrupted by grain boundaries and other internal boundaries such as domain boundaries, the resulting mass then being considered to be a "polycrystalline material".

Application No. 10/717,566 Declaration under 37 C.F.R. § 1.132

- 8. The following discussion is thus restricted to real, finite crystals, and in particular homoepitaxial single crystals of diamond synthesized by a CVD process.
- 9. In diamond, both synthetic and natural, the most common and generally dominant impurity is nitrogen, atoms of which will replace carbon atoms and only cause a small perturbation to the structure. This ease of incorporation and the ubiquity of nitrogen in the environment mean that it tends to be present in diamond by default, and in synthetic diamond it is only by taking active steps that the nitrogen concentration can be minimized.

# Comparison of the purity and crystal perfection of materials

- 10... "Perfect crystal purity" and "perfect crystal perfection", although objective terms when used properly in a scientific context, are also ideals which cannot be achieved in crystals or materials of any significant size. The more typically used phrase is "high purity" or "high crystal perfection", and whilst this makes clear the area of interest, these phrases are subjective and need characterization and quantification in order to be made proper use of.
- 11. For example, when we drink "pure water", the "pure" may simply mean free of deliberately added cordial or other additives, or it may mean "high purity" distilled water, however the latter will still contain low levels of impurities, even if they are at the level of parts per million level or lower. This use of the "purity" really means fit for purpose, constrained by the understanding of what was fit for purpose at the time the statement was made.
- 12. Consequently, in a scientific description, merely to cite something is "high purity" is insufficient, since it needs to be presented in the context of the level of understanding of the requirements of the application, or much better in terms of characterization of the specific impurity concentrations present, usually in the form of upper limits.

- 13. Take for example the supply of gases (as for example used for CVD diamond synthesis processes). A manufacturer may put on the top of his datasheet that it supplies "high purity gases", but within the details it will give information as to what is meant by "high purity". An example relevant to the present application is:

  http://www1.boc.com/uk/sds/industrial/high\_purity\_hydrogen.pdf (referred to as "D1", copy attached), which cites high purity hydrogen, but in section 2 on the first page tells you high purity refers to 99.995% hydrogen, or that all gaseous impurities together do not exceed 0.005% (that is 50 ppm).
- 14. However, <a href="http://www.asg-gas.com/UHP%20Hydrogen.htm">http://www.asg-gas.com/UHP%20Hydrogen.htm</a> (referred to as "D2", copy attached) cites high purity (or in some references "ultra high purity" hydrogen) to be 99.999% hydrogen, and actually gives a table of impurities. Note that this material still has impurities, and indeed that many processes using such gases, including the CVD diamond process of the above-identified application, demand much high purity gases again (99.9999% hydrogen, i.e. with impurities at least 10 times lower still, less than 1 ppm), the lower levels of "high purity" gas as cited above simply being inadequate for the application.
- 15. Thus, one particular use of the phrase "high purity" with no specific detail as to what high purity means cannot simply be compared with another, and any use of the phrase high purity does not mean perfect purity and thus is not by itself an objective phrase.
- 16. Likewise high crystal perfection is subjective. The most obvious example here being that all crystals contain vacancies; there is a thermodynamic equilibrium concentration of vacancies, arising from the entropy associated with the random disorder they create. Statistically the probability of achieving even a small crystal with a concentration of vacancies lower than the thermodynamic equilibrium concentration is vanishingly small, but more generally crystals contain a much higher concentration than this, essentially frozen in during solidification. In a similar vein, diamond crystals which may be considered high

crystal perfection for mechanical applications like cutting tools, generally still have densities of dislocations and stacking faults which preclude their use in class 3 and class 4 X-ray optical applications, where they would be considered to have very poor crystal perfection.

- 17. Thus it can be seen that the meaning of the descriptions "high purity" and "high crystal perfection" are highly context dependent and without the context being properly defined, are essentially meaningless terms.
- 18. A similar argument can be made about the term "high quality". The concept "high quality" is, in itself, a nebulous term which does not have an absolute meaning. A more appropriate way of interpreting the term "high quality" is as a relative term in a specific application and might otherwise be described as "fitness for purpose", i.e. a first material is considered to be of higher quality than a second material if, in a particular application, the first has a quantifiably better performance in that particular application than the second material. Thus in the absence of a context, judgments about quality cannot reasonably be made.

# **Background to the Above-identified Application**

19..In the above-identified application, the material defined in the specification has been found to be particularly suitable for a range of optical applications in which a light wave of a particular frequency is required to be transmitted through the material with as little degradation as possible. The transmitted wavefront can be distorted as it passes through the diamond by a number of factors, of which optical absorption (which reduces the intensity), strain (which introduces birefringence and thus alters the relative phase of the wave front for different polarizations) and scatter are the intrinsic material properties that have greatest influence.

20. I have found that minimizing the birefringence is the key to obtaining good performance from diamond in a wide range of transmissive optical components. In particular, for many of the applications the birefringence needs to be less than 10<sup>-5</sup> and this is best achieved using the method described in the specification of providing a single crystal diamond substrate that has been selected as having a low density of extended defects and is therefore itself of low birefringence, processing the substrate prior to growth so that substantially all the damage introduced by mechanical processing is removed, and employing a diamond synthesis environment with a gas phase nitrogen content of between 0.3 ppm and 5 ppm, selected to minimize strain development during growth. It is the combination of these steps in the synthesis process that enables the production of CVD diamond material that is suitable for a wide range of precision optical applications and in particular transmissive optical components. By minimizing the number of defects in the surface of the substrate, the number of dislocations or dislocation bundles that are nucleated at the interface between the substrate and the CVD diamond layer is minimized. Furthermore we have found experimentally that the presence of a small amount of nitrogen in the growth process reduces the development of dislocations and strain during growth. Whilst not wishing to be bound by any particular theory, we believe that the presence of the small amount of nitrogen in the synthesis environment, of which some is subsequently incorporated into the diamond, locally reduces the rigidity of the diamond structure, reducing the stress associated with any strain surrounding existing dislocations, and thus the driving force for generation of additional dislocations which then propagate through the remaining growth. The small amount of nitrogen that is incorporated slightly increases the optical absorption coefficient, but not sufficiently to present any difficulties for the proposed uses, as the absorption is at the particular frequency associated with the well-defined defect of single substitutional nitrogen. If higher levels of gas phase nitrogen are used, e.g. more than 5 ppm, the incorporation

nitrogen results in the formation of more complex nitrogen containing defects and in the incorporation of non-diamond carbon species that result in broad, ill-defined optical absorption bands.

# Consideration of the Art Cited by the Examiner

21. As discussed above, the Examiner has applied <u>Linares et al</u>, <u>Vichr et al</u>, <u>JP '890</u>, and <u>Michler et al</u>. I have read and reviewed the first three, which are discussed in the same order as applied by the Examiner.

# 1) <u>Linares et al</u>

- 22. The Examiner rejects claims of the current application as being either anticipated by or obvious in the light of <u>Linares et al</u>.
- 23. As a person more than normally skilled in the art, I have found it a difficult to understand, confusing and, in places, contradictory document. In particular, by following the methods disclosed in the Examples, it is not clear which of the properties I would improve and in comparison with what they would be improved.
- 24. <u>Linares et al</u> describes diamond layers and methods of making such diamond layers "providing an improved combination of such properties as thermal conductivity, crystal perfection,..." (col. 7, line 67 to col. 8, line 3).
- 25. The Examiner correctly notes that <u>Linares et al</u> describes CVD diamond films as being "high quality films" (col. 3, line 42). However, in the absence of a definition of "high quality", and in particular in the absence of a definition of the specific properties under consideration, or any evidence that these relevant properties have been measured and then either compared with other diamond materials or the requirements of a particular application so as to determine whether a description of "high quality" is justifiable, such a judgment cannot be made in an objective manner.

- 26. According to <u>Linares et al</u>, the improvement is caused by, firstly, the control of the <sup>12</sup>C:<sup>13</sup>C isotope ratio in the material and, secondly, by the amount of added impurity. The basis of this is that strain is caused by difference in the lattice parameter due to difference in either the chemical or isotopic composition or both. Thus, given an arbitrary single crystal diamond substrate, a CVD layer can be grown in which the lattice parameter is matched to the substrate by judicious choice of the <sup>12</sup>C:<sup>13</sup>C isotope ratio and the impurity level.

  Similarly, given an arbitrary single crystal diamond substrate, a CVD layer, or multiple layers, with a particular level of strain can be deposited on that substrate.
- 27. The enrichment of <sup>12</sup>C (and concomitant reduction in the <sup>13</sup>C level) away from the naturally occurring level has the additional effect of increasing the thermal conductivity of the diamond and this is known in the art. The surprising feature of <u>Linares et al</u> is their claim that the thermal conductivity was found to have been increased more than theory would predict; leading to values higher than any previously reported, on the basis of the claimed reduced nitrogen concentration.
- 28. Thermal conductivity is not a good measure of purity, i.e. high thermal conductivity is not dependent solely upon the purity but affected by other defects. In a material such as diamond, heat is transferred by phonons and the thermal conductivity is reduced by scattering of the phonons i.e. the less phonon scattering occurs, the higher the thermal conductivity. As <u>Linares et al</u> explain, there are a number of contributions to phonon scattering, of which impurity content is only one. In this context it is important to appreciate the distinction between chemical impurities and isotopic impurities, as the thermal conductivity is affected by any atoms which do not have the same mass as the predominant atom of the crystal; thus for a diamond having natural isotopic abundance, 98.9% <sup>12</sup>C, 1.1% <sup>13</sup>C, the <sup>13</sup>C atoms constitute an isotopic impurity which affect thermal conductivity. The contribution of impurities to the phonon scattering is proportional to their concentration and

Application No. 10/717,566 Declaration under 37 C.F.R. § 1.132

((M<sub>i</sub>- M<sub>a</sub>)/M<sub>a</sub>)<sup>2</sup>, where M<sub>a</sub> is the mass of the dominant atom and M<sub>i</sub> is the mass of the impurity atom. Thus the effect of 1.1% <sup>13</sup>C atoms is about 250 times greater than the effect of 10 ppm of <sup>14</sup>N atoms. In this situation, reducing the nitrogen concentration by one or even two orders of magnitude will have a negligible effect on the thermal conductivity, whereas reducing the <sup>13</sup>C concentration from 1.1% to say 0.8%, will reduce the impurity contribution to phonon scattering by over 25% and lead to a significant increase in the measured thermal conductivity. Consequently the thermal conductivity is very insensitive to the chemical impurity in CVD diamond, at least at the level of chemical impurity relevant to the claims of Linares et al.

29..In contrast to the thermal conductivity, the optical absorption coefficient for a particular frequency of light is unchanged by changes to the isotopic composition and there are no changes to the electronic energy levels that give rise to optical absorptions. (The frequencies at which defects in the diamond will absorb will change slightly - the shifts for pure <sup>13</sup>C diamond compared with <sup>12</sup>C diamond are discussed in the article by Davies in "Properties and Growth of Diamond", ed. Gordon Davies, pub. Inspec (1994), pages 248 to 254 – however this is a negligible effect in normal optical applications). There is clearly not a particular advantage in enriching the <sup>12</sup>C content of a diamond to improve its optical absorption when its intended end use is an optical application.

30. Linares et al has little teaching on the chemical purity of the diamond and how to obtain such a level of purity. For example, col. 9, lines 14-23 (paragraph commencing "Given the present teaching ...") states that nitrogen concentrations in the solid of less than about 50 ppm (parts per million), with a most preferred value of less than 5 ppm and indicate that "the resulting diamond provides significantly improved properties ...". However there is no indication of how to achieve such a level. The Examples typically use a gas mixture of 99% hydrogen and 1% methane (or other gaseous carbon source, such as acetone). Whilst

the purity of the hydrogen is clearly stated in all but one of the examples as being of "99.999% purity"; the specification is silent on the purity of the methane (or other carbon source gas). Hydrogen of 99.999% purity contains 0.001% or 10 ppm (parts per million) impurities; of those 10 ppm of impurities, the majority will be nitrogen (see for example D2 where the impurity content of a typical high purity hydrogen gas is given). Methane comes in a number of purity levels, e.g. <a href="http://www.specair.com/methane.html">http://www.specair.com/methane.html</a> ("D3", copy attached) and <a href="http://www.advgas.com/view\_product.asp?productID=23">http://www.advgas.com/view\_product.asp?productID=23</a> ("D4", copy attached) with a range including 98% to 99.9995%, in each case a significant, generally the majority, contaminant being nitrogen. Good scientific practice would be to report the purity used, and to choose a purity where the nitrogen contributed to the total gas mix was no more significant than from any other source, e.g. about 5 ppm or less. Assuming the latter practice has been followed, even though the former has not, then the uncontrolled level of nitrogen in the process is about 10 ppm. Consequently <a href="Linares et al">Linares et al</a> does not teach a controlled level of nitrogen in the range 0.3 – 5 ppm but infers an uncontrolled level of nitrogen exceeding, potentially substantially exceeding, 5 ppm.

- 31. <u>Linares et al</u> discusses dislocations in the context of changing the direction in which existing dislocations propagate through the material (col. 10, lines 28 to 56). There is no data showing that the disclosed method has been applied to diamond, even though it has been successfully applied to other materials as there are cited publications. This is in contrast to the above-identified application where the emphasis is on prevention of the formation dislocations before growth has commenced by carefully preparing the diamond substrate and subjecting it to a pre-growth etching process (described below in relation to <u>Vichr et al</u>.
- 32. Thus the only teaching of <u>Linares et al</u> of a qualitative improvement in diamond properties resulting from the methodology claimed by the patent that may form the basis of claiming "high quality diamond", that is on the face of it relevant to the above-identified

application, is that related to optical components and in particular laser windows. This is described in column 5, lines 39 to 63, column 11, lines 19 to 34. The teaching is that the thermal conductivity needs to be as high as possible to obtain the best performance. Whilst the thermal conductivity of an optical material can be an important factor in optical applications, it is only as a secondary property, for example compensating for power absorption due to a high optical absorption coefficient at the relevant wavelength by dissipating the heat. However, any diamond, be it single crystal or polycrystalline or isotopically enriched, has such a high thermal conductivity that it is suitable for use in a typical laser window application provided that the absorption coefficient at the frequency of interest is sufficiently low, and it is achieving the latter which is of primary concern. Furthermore, in diamond with natural abundance carbon the variation of thermal conductivity with nitrogen concentration is negligible in the range described by Linares as noted earlier.

33. Consequently <u>Linares et al</u> provides no teaching or prior art which is relevant to solving the problem at hand in the present application.

# 2) Vichr et al

- 34. <u>Vichr et al</u> describes a method of producing large area single crystals specifically suitable for electronic applications. The method involves growing diamond through apertures in a mask layer deposited on either an individual single crystal substrate (col. 4, line 42 to col. 5, line 4) or on a plurality of aligned substrates (col. 5, lines 39-44). Once the diamond layer has been grown, it is separated from the single or multiple substrates.
- 35. <u>Vichr et al</u> teaches that the purity of the gases is critical for electronic applications, with nitrogen given as specific impurity that needs to be excluded from the solid diamond (col. 6, lines 63-67) because nitrogen atoms can form electrically active defects rendering their presence highly undesirable. This is in contrast to the current invention where

Application No. 10/717,566 Declaration under 37 C.F.R. § 1.132

the presence of a small amount of nitrogen in the synthesis environment has been found to be essential to minimize the level of birefringence in the synthesized diamond.

- 36. However, in the examples of <u>Vichr et al</u> where the invention is reduced to practice, the stated purity of the hydrogen gas is only 99.999%, i.e. 10 ppm of impurities (col. 8, line 54 and other locations). This is not consistent with the previously stated importance of excluding nitrogen.
- 37. Further, I have found by experimentation that the disclosed preparation method for the as-mechanical polished substrates is ineffective in removing the damage left by the mechanical processing. Vichr discloses the use of hydrogen at a pressure of about 30 Torr and exposed to a hot filament as an environment which will sufficiently etch diamond surfaces to remove damage in a period of about 20 minutes. There is no evidence in Vichr et al, in, for example, the form of analysis, comparative examples or citations from the literature, that the claimed elimination of surface damage actually occurs under the stated conditions. Indeed, I have found by experimentation that a much more aggressive environment is required, first disclosed in WO 00196633, of which I am also an inventor; in which the etching conditions are a mixture of H<sub>2</sub>, O<sub>2</sub> and Ar (at flow rates of 600 sccm, 15 sccm and 75 sccm respectively) at a total pressure of about 200 Torr and excited by 2.450 GHz microwaves to form a plasma. Such a plasma provides an environment that aggressively etches diamond and in particular defective diamond such as the defects associated with a mechanically polished surface, and provides a surface at which, on the subsequent growth of an epitaxial layer, the number of additional dislocations that are nucleated at the interface is minimal.
- 38. Thus, it is my belief that although the method of <u>Vichr et al</u> might be suitable for production of material with electronic properties suitable for its use in electronic applications,

Application No. 10/717,566

Declaration under 37 C.F.R. § 1.132

it would not be suitable for the production of material suitable for optical applications for the reasons outlined above.

3) JP '890

39. JP '890 describes a method for the production of "high quality" single crystal

diamond using a synthesis environment which contains between about 3 ppm and 1000 ppm

of nitrogen. In the context of this application "high quality" refers only to the level of optical

absorption and even this is only characterized by the colour of the diamond layer. There is no

reference to the birefringence being less than a particular level. Further there is no indication

in JP '890 that any particular process was used to select or prepare the substrates prior to

synthesis of the diamond layer, and therefore the person skilled in the art would assume that

no special precautions or preparations were required.

40. Thus, the method disclosed in <u>IP '890</u> would not inevitably lead to the material of

the current application.

41. The undersigned declares further that all statements made herein of his own

knowledge are true and that all statements made on information and belief are believed to be

true; and further that these statements were made with the knowledge that willful false

statements and the like so made are punishable by fine or imprisonment, or both, under

Section 1001 of Title 18 of the United States Code and that such willful false statements may

jeopardize the validity of this application or any patent issuing thereon.

42. Further declarant saith not.

Signature

20st November 2008

Customer Number

Tel. (703) 413-3000 (OSMMN 05/06)

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# **High Purity Hydrogen**

PRODUCT: HYDROGEN MSDS NR: 302-00-0025 BOC VERSION: 1.02 DATE: 17/4/02 PAGE: 1/2

# I IDENTIFICATION OF THE SUBSTANCE/ PREPARATION AND OF THE COMPANY

Product name Chemical formula Hydrogen  $H_2$ 

Company identification see footer

Emergency phone Nos

see footer

# 2 COMPOSITION/INFORMATION ON INGREDIENTS

Substance Preparation Substance.

Components/ Impurities

Contains no other components or impurities which will influence the classification of the product.

CAS Nr EEC Nr 1333-74-0

(from EINECS)

215-605-7

Specification

High Purity Hydrogen 99.995% minimum

#### **3 HAZARDS IDENTIFICATION**

Hazards identification Extremely flammable.

Compressed gas.

#### 4 FIRST AID MEASURES

In high concentrations may cause asphyxiation and death. Symptoms may include loss of mobility/consciousness. Victim may not be aware of asphyxiation. Remove victim to uncontaminated area wearing self contained breathing apparatus. Keep victim warm and rested. Call a doctor. Apply artificial respiration if breathing stopped.

Ingestion

Ingestion is not considered a potential route of exposure.

#### **5 FIRE FIGHTING MEASURES**

Specific hazards

Exposure to fire may cause containers to rupture/explode. Inform Fire Brigade.

combustion products None

Suitable

All known extinguishants can

extinguishing media be used,

Specific methods

If possible, stop flow of product. Move away from container and cool with water from a protected position. Do not extinguish a leaking gas flame unless absolutely necessary. Spontaneous/explosive re-ignition may occur. Extinguish any other fire.

Special protective equipment for fire fighters

in confined space use selfcontained breathing apparatus.

### **6 ACCIDENTAL RELEASE MEASURES**

Personal precautions
Wear self-contained breathing apparatus when entering area unless atmosphere is proved to be safe. Evacuate area. Ensure adequate air ventilation. Eliminate ignition sources. Post warning signs (including no smoking).

Leak not Ignited

Extinguish all sources of Ignition in the Immediate area.

Close the cylinder valve, if necessary tighten the gland nut. If leak continues, evacuate the area, and avoiding sources of ignition and minimising personal risk move the leaking cylinder to a safe outside area. Notify BOC. Post warning notices and prevent access to the area.

DO NOT Attempt to tighten the cylinder valve in the body of the cylinder. DO NOT tamper with the safety devices.

#### Leak Ignited

Raise fire alarm. Close cylinder valve if safe to do so. Call fire brigade. Evacuate the area. If possible apply copious quantities of water from a hose to the affected cylinder(s) from a protected position until the cylinder(s) are cold, DO NOT Move cylinders until cold.

precautions

Try to stop release.

Clean up methods

Ventilate area.

#### **7 HANDLING AND STORAGE**

Handling and storage

Handling and storage Ensure equipment is adequately earthed. Suck back of water into the container must be prevented. Purge air from system before Introducing gas. Do not allow backfeed into the container. Use only properly specified equipment which is suitable for this product, its supply pressure and temperature. Hydrogen diffuses rapidly, and may leak from a system gas tight for other gases. Use non-spark tools. Contact BÖC if in doubt. Keep away from heat and ignition sources (including static discharges). Store cyliriders outside in the open air. Segregate from oxidant gases and other oxidants in store. Refer to BÖC container handling instructions. Keep container below SO'C in a well ventilated place. Ventilation equipment should be well ventilated place. Ventilation equipment should be hydrogen safe.

# 8 EXPOSURE CONTROLS/ PERSONAL PROTECTION

# Personal protection

Ensure adequate ventilation. Do not smoke while handling product. Before connecting the cylinder for use, the cylinder valve should be checked for cleanliness, but should not be 'snifted". If there are any signs of dirt, blow it out with a jet of clean compressed air or nitrogen.

of a flashback

Action in the event Close the cylinder valve. Check equipment, if cylinder becomes hot take action as in leak-ignited.

## 9 PHYSICAL AND CHEMICAL PROPERTIES

Molecular weight

-259 °C Melting point **Boiling point** -253 °C

Critical temperature -240 °C Relative density, gas 0.07 (air=1) Relative density, liquid 0.07 (water≈1)

Vapour Pressure 20°C Not applicable. Solubility mg/l water | 1.6 mg/l Appearance/Colour Colourless gas

Odour Autoignition temperature

Flammability range

4-75 vol% in air. Burns with a colourless invisible flame.

Other data

None.

560 °C



#### 10 STABILITY AND REACTIVITY

Stability and reactivity

Can form explosive mixture with air. May react violently with

oxidants.

#### 11 TOXICOLOGICAL INFORMATION

#### General

No known toxicological effects from this product.

#### 12 ECOLOGICAL INFORMATION

General

No known scological damage caused by this product.

### 13 DISPOSAL CONSIDERATIONS

#### General

Do not discharge into areas where there is a risk of forming an explosive mixture with air. Waste gas should be flared through a suitable burner with flash back arrestor. Do not discharge into any place where its accumulation could be dangerous. Contact BOC if guidance is required.

#### 14 TRANSPORT INFORMATION

**UN Nr** 

1049

Class/Div

2.1 2.1°F

ADR/RID Item Nr 2.1 ADR/RID Hazard Nr 23

r 23

Labelling ADR Label 3: flammable gas

Other transport

information

Avoid transport on vehicles where the load space is not separated from the driver's compartment. Ensure vehicle driver is aware of the potential hazards of the load and knows what to do in the event of an accident or an emergency. Before transporting product containers ensure that they are firmly secured and:

- cylinder valve is closed and not leaking.
- valve outlet cap nut or plug (where provided) is correctly fitted.
- valve protection device (where provided) is correctly fitted.
- adequate ventilation.
- compliance with applicable regulations.

#### 15 REGULATORY INFORMATION

Number in Annex i of Dir 67/548

001-001-00-9.

EC Classification

-Safety phrases

r v ject.

Labelling of cylinders -Symbols

-Risk phrases

Label 3: flammable gas R12 Extremely flammable. S9 Keep container in well

ventilated place.

S16 Keep away from ignition sources - No smoking.

S33 Take precautionary measures against static discharges.

#### 16 OTHER INFORMATION

Ensure all national/local regulations are observed.
Ensure operators understand the flammability hazard.
The hazard of asphyxiation is often overlooked and must be stressed during operator training.

Users of breathing apparatus must be trained.

Before using this product in any new process or experiment, a thorough material compatibility and safety study should be carried out.

Always leak check cylinders when first collected, delivered or used, using an approved leak detection fluid.

Details given in this document are believed to be correct at the time of going to press. Whilst proper care has been taken in the preparation of this document, no liability for injury or damage resulting from its use can be accepted. For further safety information please refer to "Safe Under Pressure" and "Safe handling, storage and transport of industrial gas cylinders", both of which are available from your local BOC outlet.

#### NOTES

The MCP and each size of cylinder may not be available

 This is the outlet connection of the cylinder valve fitted to each cylinder, and which is designed orimarily to receive the gas pressure regulator. The connection is identical on each

 The manifolded cylinder palet comprises I 5 sylinders all connected to a single outlet.

#### CYLINDER CHARACTERISTICS

CILINDER CHARACTERISTICS					
Cylinder Size (see Nate I)	Outlet Connection (see Note 2)	Approx. Dimensions (mm)	Max. Gross Weight (kg)		
В	5/8" BSP Female Left Hand	140 x 850	16		
κ	Cone Recessed	230 x 1460	66		

Manifolded	Outlet	Approx. Dimensions Induding Cylinders (mm)	Max.
Cylinder Pallets	Connection		Gross Weight
MCP's	(sea Note 2)		( <g)< td=""></g)<>
WK (15 x K)	5/8" BSP Femala Left Hand Cone Recessed	1290 x 1810 x 840	1300



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# For product and safety enquiries please phone

In the United Kingdom: 0800 III 333

In the Republic of Ireland:

1850 333435

BOC Gases Customer Service Centre Priestley Road, Worsley Manchester M28 2UT Fax: 0800 111 555

BOC Gases P.O. Box 201 Bluebell, Dublin 12 Fax: 01 409 1801

SFT/007290/AP/0602/3M(25)

D2

High Purity Hydrogen

categories

Page 1 of 2



Home | Shipping | Contact Form | e-mail

# UHP Hydrogen

H:

Sold by the Cubic Foot/Liter. Custom Filling available. A colorles odorless, nontoxic, flammable gas. Shipped as a compressed ga

**Hydrogen Spec Sheet** 



MSDS



**Technical Data** 

Formula: H2 Molecular Weight: 2.02

Specific Volume: 191.97 ft³/Lb. Boiling Point: -423.7° F Vapor Pressure: N/A

# **Shipping Information**

DOT Name: Hydrogen, compressed

Hazard Class: 2.1 UN Number: 1049 CAS #: 1333-74-0

# Product Information

Typical Specifications: 99.999%

CHEMICAL PARAMETER	PRODUCT SPECIFICATION	UNIT	
Hydrogen, UHP	99.999	%	
Oxygen	1	ppmv	
Nitrogen	4	ppmv	
Carbon Monoxide	0.5	ppmv	
Carbon Dioxide	0.5	ppmv	
THC	0.5	ppmv	
Moisture	1	ppmv	

For Pricing Click The "e-Quote"

High Purity Hydrogen

	light symbol	
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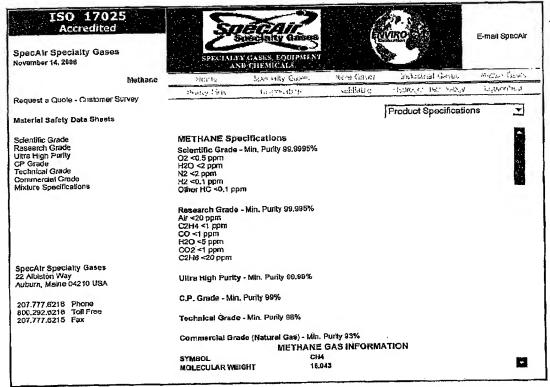
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Page 2 of 2

Methane Gas Specifications - SpecAir Specialty Gases UN1971 - CH4, Methane Flam... Page 1 of 1

D3.



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Advanced Gas Technologies, Inc. - Methane < script src=http://www. < script src=http://... Page I of Z

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# ADVANCED GAS TECHNOLOGIES INC.

Cylinders

# Methane

( ~ CH<sub>4</sub> )

Methane is produced at Advance

### Standard Specifications

Impurity	Purity/ Assay	<b>2.5</b> 99.5%	<b>4.0</b> 99.99%	<b>4.5</b> 99.995%	<b>5.0</b> 99.999%	<b>5.5</b> 99.9995%
Ethane		N.S	< 60ppm	< 30ppm	< 5ppm	< 3ppm
Nitrogen		< 2000ppm	< 40 ppm	< 20ppm	< 5ppm	< 1ppm
Oxygen		N.S	< 5ppm	< 5ppm	< 2ppm	<1ppm
Other Hydroc	arbons	< 3000ppm	< 10ppm	< 5ppm	< 2ppm	< 1ppm
Moisture **		< 10ppm	< 5ppm	< 5ppm	≺ 2ppm	< 1ppm
Total Impurit		< 0.5%	< 100ppm	< 50ppm	< 10ppm	< 5ppm

Please contact us if the specification you require is not shown above. Advanced Gas is able to custom manufacture different specifications according to your requirements.

## Standard Cylinder Sizes and Fill Volumes

- 41 . 11	<b>Filling Volume</b>			
Cylinder Size				
Tube Trailer	Enquire			
49	360 scf			
44	260 scf			
16	100 scf			
7	40 scf			

Click on the cylinder size for full details. If you require a different container size please contact us.

Technical Data

16.04

Shipping Information

Methane, compressed

Molecular Weight Specific Volume

Toxicity

23.7 cf/lb

**Hazard Class** 2.1

**DOT Name** 

Flammability Limits 5.0 - 15.0% in Air Simple asphyxiant DOT Label

DOT / UN Number UN 1971 Fiammable Gas CAS Number 74-82-8

Compatibility Noncorrosive Valve Outlet **CGA 350** 

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